

# Inelastic Neutron scattering:

Probability of scatter includes zero and one-phonon terms (Fermi golden rule). (Also higher-order.)

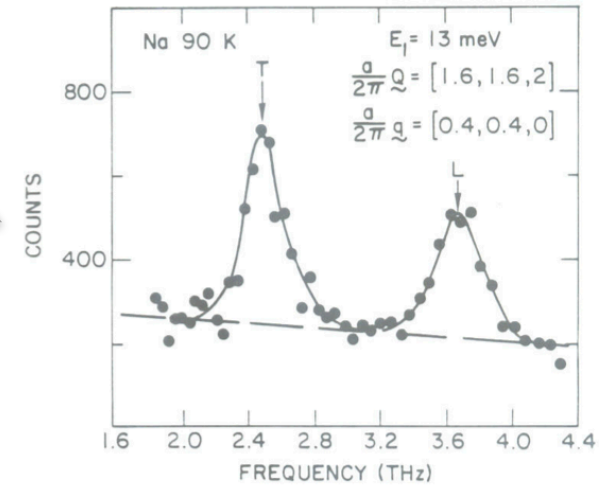
$$P \propto \left| \langle \psi | H_0 + H_1 + \dots | \psi \rangle \right|^2$$

Interaction of neutron with solid

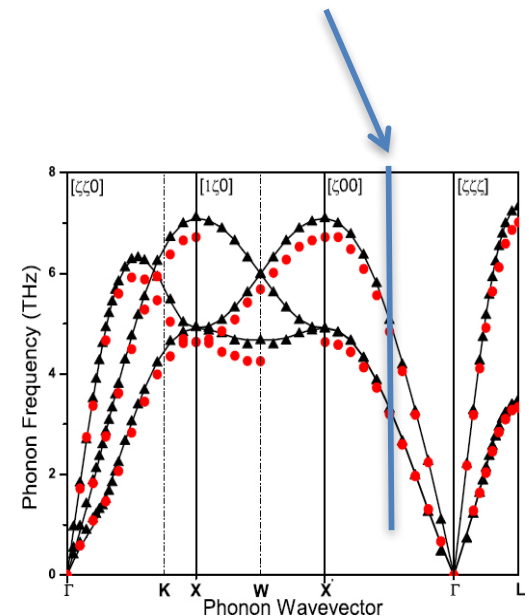
$H_0 \Rightarrow$  bragg scattering

$H_1 \propto \hat{u}$  (or  $Q_q$ ) recall  $\sim$  sum of  $a$  and  $a^\dagger$   
 (One phonon term.)  
 gives isolated peaks.

$H_2$  and higher: broad background.  
 (also, incoherent static atom displacements & impurities contribute broad signal.)



Example, scanned energy transfer, giving phonon dispersion curves.



# Neutron scattering:

Probability of scatter includes zero and one-phonon terms (Fermi golden rule). (Also higher-order.)

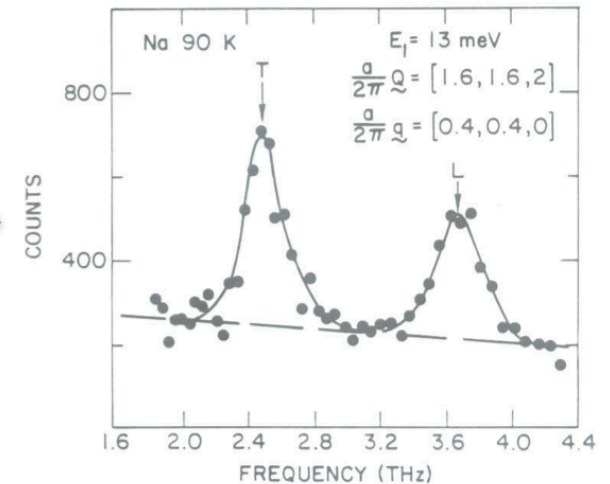
## Selection rules:

$$\Delta \vec{k} = \vec{K} \pm \sum \vec{q}$$

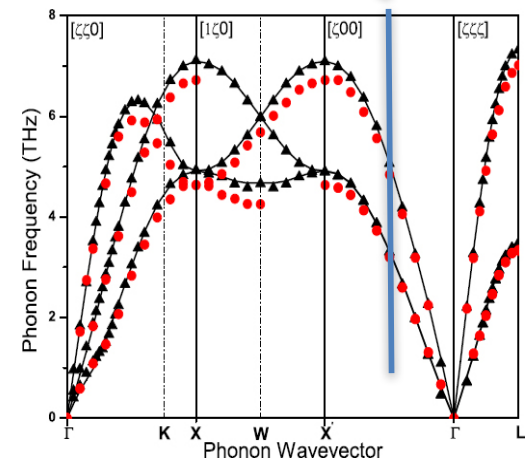
$$\Delta \varepsilon = \pm \sum \hbar \omega_q$$

Note we saw similar selection rules for photons;

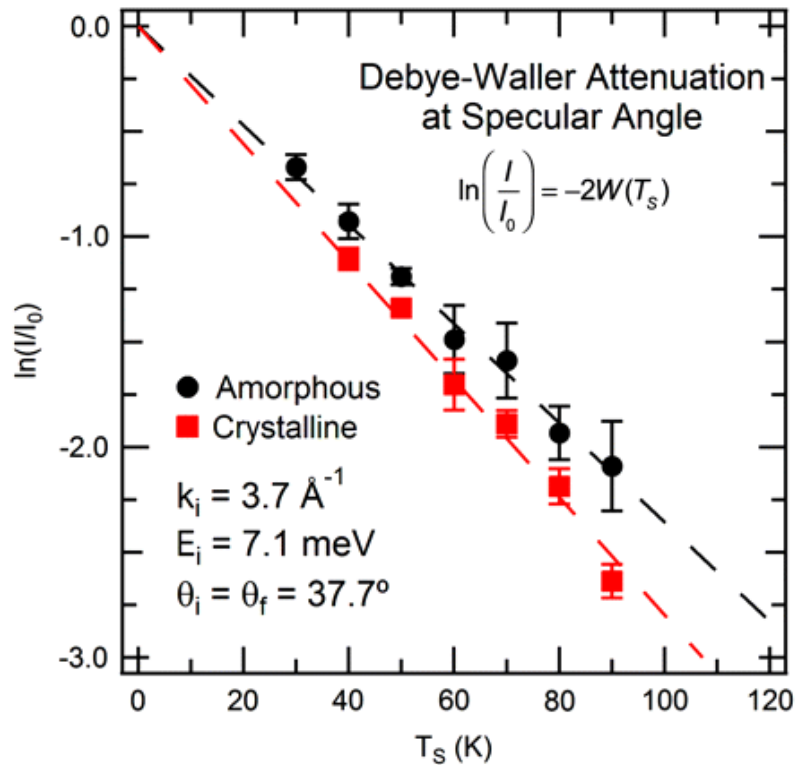
- However Raman generally measures phonons at  $\Gamma$ .
- Resonant inelastic x-ray (RIXS) recently developed, capabilities somewhat similar to neutrons.



Example, scanned energy transfer, giving phonon dispersion curves.



## Bragg scatter intensity: Debye-Waller factor



Elastic scattering decrease vs.  $T$

– appendix N.

Debye-Waller Factor: phonon scattering increases linear in  $T$ , high  $T$ ;  
elastic peaks decrease initially linear in  $T$  (full solution is exponential drop).

(Appendix N of A&M)

Displaced atom  $H \propto \hat{u}$  (or  $q$ )

Contribution of phonons:

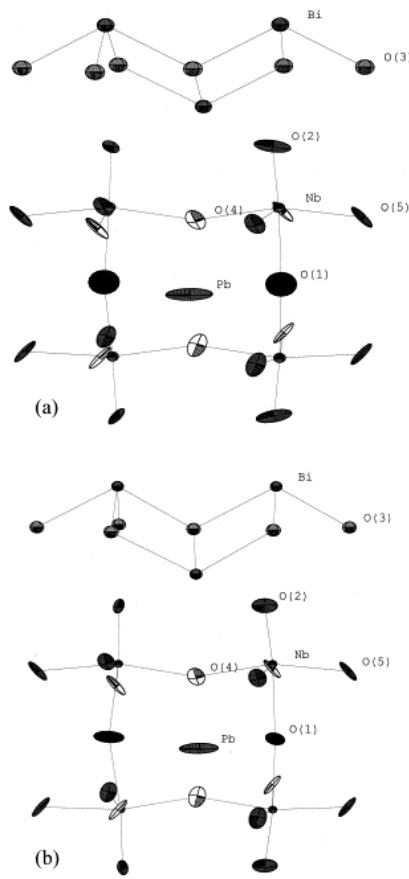
Intensity = square amplitude:  $I \propto \langle u^2 \rangle$

So,  $\langle u^2 \rangle \propto |\langle \psi' | a | \psi \rangle|^2$  etc.

$\propto$  sum of  $n(T)$

$$n = \frac{1}{e^{\hbar\omega/kT} - 1} \propto T, \text{ high } T$$

Xray analysis & displacement ellipsoids for  $\text{PbBi}_2\text{Nb}_2\text{O}_9$  ferroelectric; Ismunandar et al. Solid State Ionics 112, 281 (1998)



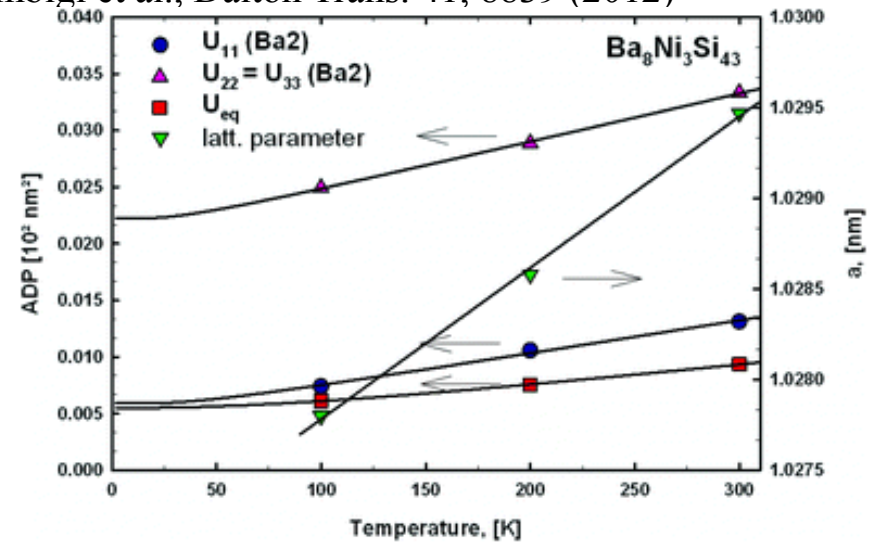
Generally static + dynamic disorder both reduce x-ray peaks. Often plotted as thermal displacement parameters.

displacement parameter T dependence

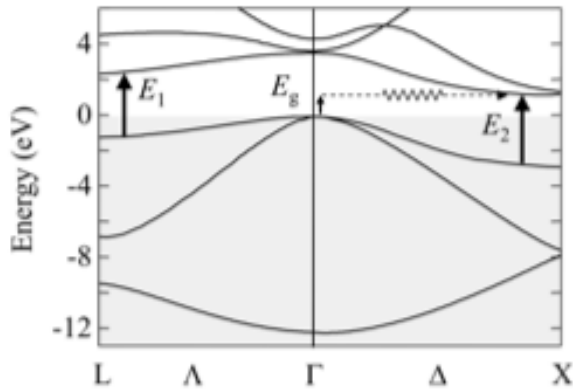
Allows to resolve dynamic vs. random static (here  $T \rightarrow 0$  disorder)

Falmbigl et al., Dalton Trans. 41, 8839 (2012)

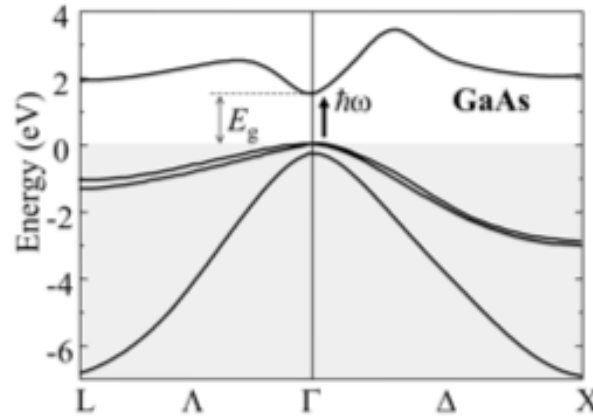
$$\langle u^2 \rangle$$



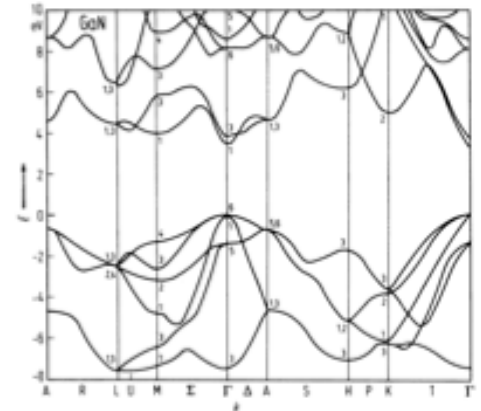
# Semiconductors:



Silicon band structure

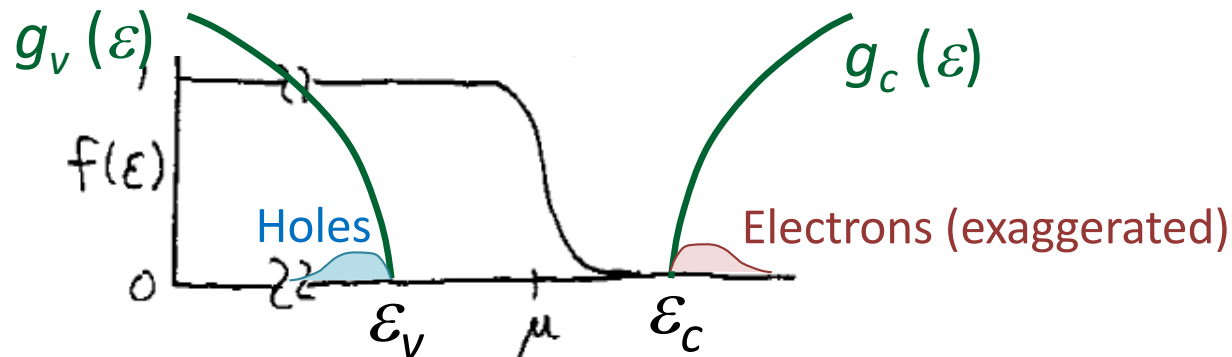


GaAs: zinblende (ZnS)

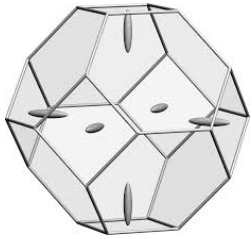


GaN: wurtzite

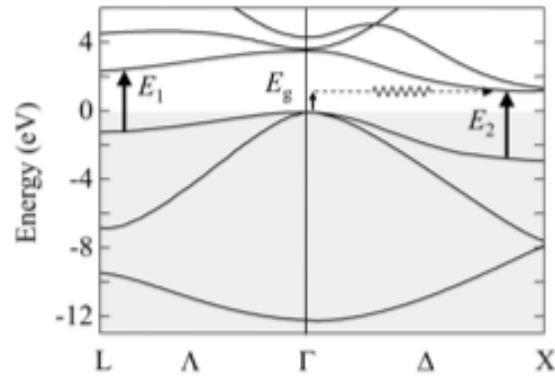
Material	Group IV			III-V						II-VI		
	Si	Ge	C	AlAs	GaAs	InAs	InP	GaSb	InSb	GaN	HgCdTe	ZnO
Bandgap (eV)	1.11	0.67	5.5	2.16	1.43	0.354	1.34	.726	0.17	3.4	0 - 1.47	3.4
Electron mass (or $m_e$ )	0.98	1.64	1.1	0.1	0.063	0.027	0.073	0.042	0.014	0.19	~0	0.27
Electron mass (transverse)	0.19	0.082	0.22	-	-	-	-	-	-	-	-	-
light hole mass	0.16	0.044			0.082	0.026	0.089	0.05	0.015			
heavy hole mass	0.49	0.28	0.25		0.51	0.41	0.6	0.4	0.43	0.8		
Electron Mobility ( $\text{cm}^2/\text{V.s}$ )	1350	3900	2800	180	8500	40000	5400	3000	77000	500		
structure	diam	diam	diam	ZnS	ZnS	ZnS	ZnS	ZnS	ZnS	wurtzite	ZnS	wurtzite
Lattice Constant (Å)	5.43	5.66	3.57	5.66	5.65	6.06	5.87	6.09	6.48			



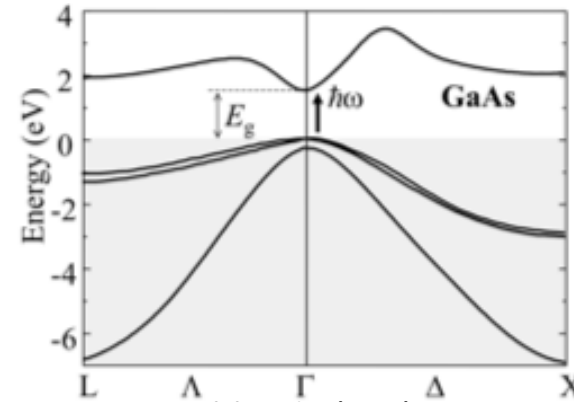
# Semiconductors:



Silicon conduction-band pockets (M. Marder)

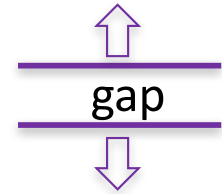


Silicon band structure



GaAs: zincblende (ZnS)

conduction bands  
(nominally empty)



valence bands  
(filled)

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Si & Ge indirect gap  
(poor optical behavior)

- AlAs, GaAs: matching lattice constants; red LED's, fast electronics (high mobility)
- n-InSb extremely high mobility / small mass
- $(\text{In}_{1-x}\text{Ga}_x)(\text{As}_{1-y}\text{P}_y)$ : IR telecommunication lasers
- GaN blue/white LED's;  $\text{In}_x\text{Ga}_{1-x}\text{N}$  Blu-ray players

$\text{Hg}_{1-x}\text{Cd}_x\text{Te}$ , Very long-wavelength IR detectors.  
Original topological insulator.